Effect of heating rate on oxidation process of fine-dispersed ZnS:Mn obtained by SHS

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Abstract. The influence of annealing at 350 °C in air atmosphere on the luminescent characteristics of powdered ZnS: Mn obtained by self-propagating high-temperature synthesis has been studied. It was shown that variation in material heating rate due to changes in the annealing temperature results in different behavior of oxidative processes. It has been ascertained that the slow heating of powdered ZnS:Mn, compared with the rapid one in the presence of oxygen, promotes active oxidation of ZnS and formation of Frenkel pairs, increases mileage of defects acting as sensitizers, and their localization near Mn2+. The model which explains the observed changes in the luminescence and PLE spectra has been presented.

Keywords: ZnS:Mn, luminescence, oxidation, self-propagating high-temperature synthesis.

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1. Introduction

Phosphors are increasingly used in various semiconductor and display devices. Basic requirements for fluorescent light sources are an effective transformation of the excitation energy to the visible light energy, stable emission in a given spectral range and low power consumption [1]. In this regard, more interests arose to devices based on the phenomenon of electroluminescence (EL) as an alternative to lamps of glowing and gas-discharge [2]. One of the most technologically simple devices based on this phenomenon is an electroluminescent condenser based on powder electrophosphors. One of the advantages of such devices is the possibility to make them flexible, which allows to expand their range of application [3].

To improve the efficiency of phosphor materials, it is necessary to minimize the role of surface states that act as nonradiative recombination channels and have a high impact on the electro-optical characteristics of material. For this purpose, it is responsible to provide the process of encapsulation, i.e. formation of the thin oxide layer on the surface of particles [4]. The standard process for encapsulation of zinc sulfide is provided by formation of a thin ZnO layer on their surface, which prevents contact of atmosphere with material, thereby enhancing its resistance to degradation. However, during formation of thin oxide layers on the surface of materials such as A2B6, it should be taken into account that the fluorescent properties of these materials strongly depends on the concentration of oxygen as an impurity capable to diffuse into the bulk material [5, 6].

Therefore, studying the properties of oxygen adsorption and its subsequent behavior, i.e. thin ZnO layer formation or diffusion into the bulk, which is largely determined by the thermodynamic conditions during its interaction with the surface, is obviously relevant.

The aim of this work is to study by luminescence methods the mechanisms of oxygen behavior in dependence on thermodynamic conditions of interaction with powdered ZnS:Mn.
2. Experimental procedure and results

Powdered ZnS:Mn was obtained by self-propagating high temperature synthesis (SHS) at temperatures that ensure interaction between zinc and sulfur [7-9]. Doping with the manganese impurity was carried out from MnCl during synthesis. Ratio of the starting materials was: Zn – 63 wt.%, S – 34 wt.%, MnCl – 1 wt.%. Heat treatment in air of powdered ZnS:Mn was performed in laboratory silica furnace at 350 °C. Temperature conditions of the annealing process were monitored by a thermocouple located in the zone of annealed material. The annealing time was 60 min, the time of reaching t, the temperature of the annealing was 1 and 7 hours. The time of cooling the furnace in all the cases was the same and close to 120 min.

The photoluminescence (PL) and its excitation (PLE) spectra were recorded at room temperature by using SDL-2 monochromator. To excite photoluminescence, radiation of the nitrogen laser LGI-23 (λ = 337 nm) was used. When registering PLE, excitation of the samples was carried using radiation of a xenon lamp that passed through the monochromator.

The PL spectra of the original and annealed for 7 hours samples, arranged on the basic bands with λ_{max} = 435, 456, 505, 578, 600 nm (curves 2-6). The spectra in Fig. 1 are normalized to the maximum of the band with λ_{max} = 587 nm.

Fig. 1 shows the spectra of PL for the initial and annealed ZnS:Mn samples. As can be seen from the figure, in the PL spectra of powdered ZnS:Mn two bands with λ_{max} = 455, 587 nm dominate. The wide one dominating in the spectrum and possessing λ_{max} ~ 587 nm is typical for ZnS doped by Mn. According to [10-12], it consists of several individual bands caused by various localizations of impurity Mn atoms in the crystal lattice of ZnS. The band with λ_{max} = 600 nm is associated with Mn^{2+} ions in octahedral interstices, while the band with λ_{max} = 578 nm – with Mn^{2+} ions near dislocations or point defects [10, 11] (Fig. 1).

![Graph showing PL spectra for initial and annealed ZnS:Mn samples](image)

Fig. 1. a) Spectra of PL for initial and annealed ZnS:Mn at different speed of a yield of the furnace on annealing temperature, normalized to the maximum of the spectrum. 1 – initial, 2, 3 – t, was 1 and 7 hours, accordingly. b) PL spectrum of annealed ZnS:Mn at the heating time 7 hours (1), individual bands composing the spectrum of PL (2).

The short-wave band with λ_{max} ~ 455 nm, which is present in the PL spectrum of ZnS:Mn, is complex, as it is clearly seen from Figs. 1a and 1b. In this region of PL spectra in ZnS, the following bands are observed: SA – band with λ_{max} ~ 505 nm is associated with the V_{S} [13], 456 nm band is associated with V_{Zn-Zn} [14], and the band with λ_{max} ~ 435 nm, which is due to presence of oxygen in ZnS [7, 15].

Annealing at T = 350 °C for 1 hour almost didn’t lead to changes in the spectral characteristics of PL in ZnS:Mn (Fig. 1a). At the same time, at heating the material to an annealing temperature for 7 hours, the intensity of the PL band with λ_{max} = 455 nm increased to ~1.5 times as compared to the PL band with λ_{max} = 585 nm, the spectral characteristics of which remain unchanged after annealing. As clearly seen from Fig. 1b, changes in the short-wave region of the PL spectrum of ZnS:Mn after heating for 7 hours is due to the increase of the contribution in spectrum of individual bands with λ_{max} ~ 345 and 456 nm, which is caused by oxygen impurity and Frenkel pair V_{Zn-Zn} [16, 17], accordingly. Along with it, there is a reduction of the contribution of the band with λ_{max} ~ 505 nm due to V_{S}. The intensity of the PL band with λ_{max} ~ 345 nm and decrease in the intensity of the PL band λ_{max} ~ 505 nm are probably caused by filling V_{S} by oxygen and formation of O_{S} centers. Embedding into the ZnS lattice an atom with the higher electronegativity (χ = 3.44 for oxygen [16]), instead of sulfur with the electronegativity χ = 2.58 [18], leads to an increase of the electrical moment that is responsible for piezoelectric properties of ZnS. And as it has been shown in the work [19], the presence of the electric moment causes appearance of Frenkel pairs.

PLE spectra of ZnS:Mn, presented in Fig. 2, contain five bands with the maxima located at λ_{max} = 343, 39, 424, 467 and 493 nm. The band at λ_{max} = 340 nm corresponds to the band of the fundamental excitation for ZnS [20]. The bands at λ_{max} = 391, 424,
467 and 493 nm correspond to those known from the literature [20, 21] as elementary manganese bands of PLE. These bands of PLE are caused by transitions from the ground state \( \text{Mn}^{2+} \rightarrow E_0 \) to the excited states \( ^{4}T_1, ^{4}T_{2}, ^{4}E_0, ^{4}A_1 \) [20]. It is well known [20-22] that the excitation of the Mn ion is realized with the participation of sensitization centers, whose role in ZnS:Mn is performed by closely spaced defects, Mn\( _{20} \), impurities of Cl, O etc.

As seen in Fig. 2, furnace heating for 1 hour leads in essence only to improvement of the efficiency of resonant channels, which involves excitation of Mn\( ^{2+} \) luminescence, with respect to the band-to-band channel. At the same time, the heating for 7 hours leads to more significant changes in the PLE spectra. The efficiency of resonant excitation channels of Mn\( ^{2+} \) increased even more than when heated for 1 hour, moreover, the growth of the impurity-defect band at \( \sim 372 \) nm has been so great that it became dominant in the PLE spectra. As was shown by the authors [23], the band in PLE spectra of ZnS with \( \lambda_{\text{max}} \sim 372 \) nm is due to the presence of oxygen in the lattice of ZnS, which may indicate active oxygen diffusion into ZnS under slow heating of material. The increase in intensity of manganese bands in PLE spectra reflects the efficiency of the resonance energy transfer from the sensitizer to the Mn ion. The change in efficiency of absorption channels of Mn\( ^{2+} \) occurs with changes in the symmetry of environment of Mn\( ^{2+} \) and sensitization centers as well as their closer mutual localization [24]. In consequence of ZnS:Mn heating, there increased is the mobility of Mn and defects that act as sensitization centers, which ultimately leads to their accumulation in Cottrell atmosphere [25] and closer localization. This, in turn, enhances the effectiveness of resonant excitation channels of Mn\( ^{2+} \).

3. Discussion

Much more active introduction of oxygen into the lattice of ZnS, when heating during annealing is slow, is supposed to be related with the following events. For adsorption of oxygen on the surface of ZnS:Mn, it is necessary to overcome an energy barrier \( E_{\text{A}} \) (see Fig. 3). As temperature increases, the probability to overcome the barrier increases. However, to form association of oxygen with adsorption center it needs some time (\( \tau \)). In the ideal case, when there is the coincidence of the energy states of adsorption centers and those of atoms or molecules of oxygen, i.e. the energy of oxygen \( E_{\text{O}} \) matches with the barrier height \( E_{\text{A}} \), the time required for adsorption of oxygen is the lowest one, and \( \tau \rightarrow \tau_{0} \). In the case when \( E_{\text{O}} < E_{\text{A}} \) or \( E_{\text{O}} > E_{\text{A}} \), oxygen needs the time \( (\tau_{\text{t}}) \) to obtain missing energy or to dissipate the excess of energy, then \( \tau = \tau_{0} + \tau_{\text{t}} \). Thus, if the time of oxygen localization (\( \tau \)) near the adsorption centre is more than \( \tau \) (\( \tau \geq \tau_{0} \)), then the probability of adsorption is maximal.

When the heating is rapid, the energy of oxygen \( E_{\text{O}} \) quickly reaches the value corresponding to that of barrier and quickly begins to significantly exceed it.

In this case, i.e. when \( E_{\text{O}} > E_{\text{A}} \), oxygen has enough energy to overcome the barrier, but the time that oxygen spent at the surface is less than that needed to form stable connection (\( \tau < \tau_{0} \)). At the same time, oxygen has enough energy to overcome the barrier in the opposite direction. All this leads to a decrease of the probability of its adsorption and to formation of the thin ZnO layer or subsequent diffusion of oxygen into the bulk of ZnS. In other words, during rapid heating, even when oxygen has a sufficient energy to physical adsorption, a rapid rise in temperature doesn’t accelerate formation of more stable bond and transition in chemically adsorbed state, but converts oxygen to such an energy state, at which the probability of desorption is increased.

In the case of slow heating, when the oxygen reaches the necessary energy to overcome the barrier \( E_{\text{O}} \approx E_{\text{A}} \), it has enough time to transfer to the physically adsorbed state, and then after getting the extra energy – to transfer to the chemically adsorbed state. The further rise in temperature leads to oxygen diffusion into the bulk of material.

4. Conclusion

Thus, the processes of oxidation at different heating times proceed differently. These results revealed that the rate of heating of ZnS:Mn to the annealing temperature affects on the probability of transition of oxygen from the physically adsorbed to chemically adsorbed state. When heating is more rapid, probability of oxygen desorption from the physically adsorbed state is higher than when the heating is slow.

Furthermore, the slow heating of the material, as compared with the rapid one, in the presence of oxygen promotes active oxidation of ZnS, formation of Frenkel pairs, increase of mileage of defects acting as sensitzizers, and their localization near Mn\( ^{2+} \), which, in turn, enhances the efficiency of the excitation channels of Mn\( ^{2+} \) luminescence.
References


